

## Real-space Demonstration of 0.4 Angstrom Resolution at 80 keV via Electron Ptychography with a High Dynamic Range Pixel Array Detector

Zhen Chen<sup>1</sup>, Yi Jiang<sup>2</sup>, Yimo Han<sup>1</sup>, Pratiti Deb<sup>1,2</sup>, Hui Gao<sup>3,4</sup>, Saïen Xie<sup>1,3</sup>, Prafull Purohit<sup>2</sup>, Mark W. Tate<sup>2</sup>, Jiwoong Park<sup>3</sup>, Sol M. Gruner<sup>2,5</sup>, Veit Elser<sup>2</sup> and David A. Muller<sup>1,5</sup>

<sup>1</sup>. School of Applied and Engineering Physics, Cornell University, Ithaca, NY.

<sup>2</sup>. Department of Physics, Cornell University, Ithaca, NY.

<sup>3</sup>. Department of Chemistry, Institute for Molecular Engineering, and James Franck Institute, University of Chicago, Chicago, IL.

<sup>4</sup>. Department of Chemistry and Chemical Biology, Cornell University, Ithaca, NY.

<sup>5</sup>. Kavli Institute at Cornell for Nanoscale Science, Ithaca, NY.

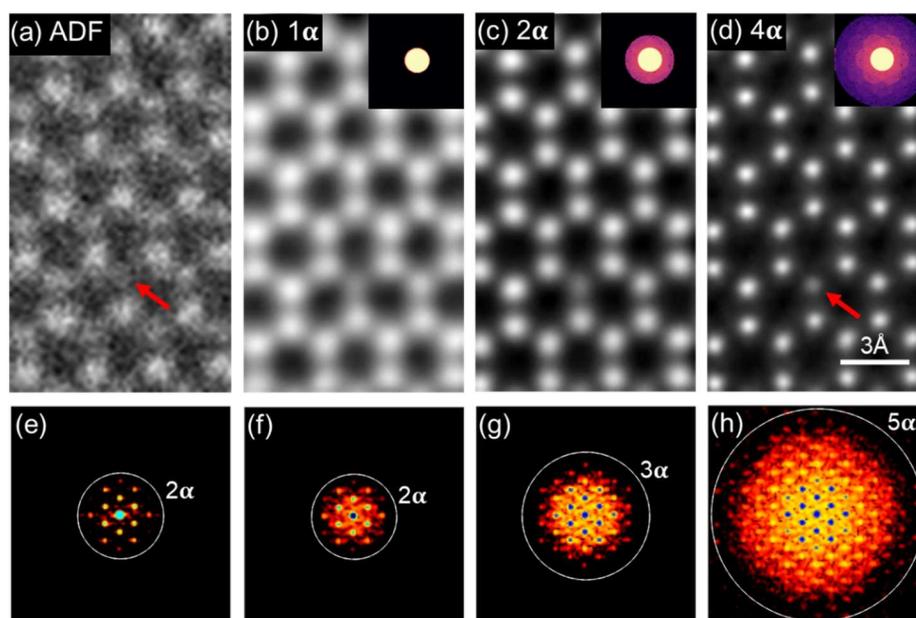
Advances in aberration corrected electron optics have made sub-Angstrom resolution microscopy widely available, with spatial resolution demonstrations reaching slightly below 0.5 Å at 300 keV [1,2]. However, at the lower beam energies needed to avoid knock-on damage while imaging two-dimensional materials, the spatial resolution is limited to slightly lower than 1 Å from residual high-order geometric and chromatic aberrations. By phasing a series of scanning diffraction patterns, electron ptychography can in principle numerically retrieve the probe and object functions with spatial resolution limited not by the numerical aperture of the lens, but by the largest scattering angle collected. To do so requires a detector that can record a full diffraction pattern, from central beam to high scattering angles, without saturation or distortion. This requires a dose rate, dynamic range and readout speed beyond that of conventional detectors.

Here, combining our new high-dynamic-range and single-electron-sensitivity electron microscope pixel array detector (EMPAD) [3] with full-field ptychography [4,5], we achieved a 0.4 Å resolution at 80 keV on an electron microscope which has ~1 Å resolution limit from conventional STEM imaging methods. Figure 1 shows the annular dark field (ADF) image and ptychographic reconstructions of a monolayer MoS<sub>2</sub> using one EMPAD dataset taken with a 21.4 mrad semi-angle ( $\alpha$ ) probe. As shown in Figure 1(b)-(d), the reconstructed atoms become sharper as higher cutoff of the diffraction patterns is used. With the entire diffraction patterns (about  $4\alpha$  cutoff), the diffractogram of the reconstructed phase shown in Figure 1(h) reaches an information limit close to  $5\alpha$  – corresponding to a 0.39 Å Abbe resolution, while at the same dose and imaging conditions conventional ADF image could hardly reach  $2\alpha$ , *i.e.*, 0.98 Å Abbe resolution. Furthermore, the image contrast of the ptychographic reconstructions is significantly improved, showing a sulfur mono-vacancy defect that can be barely seen in the noisy ADF image.

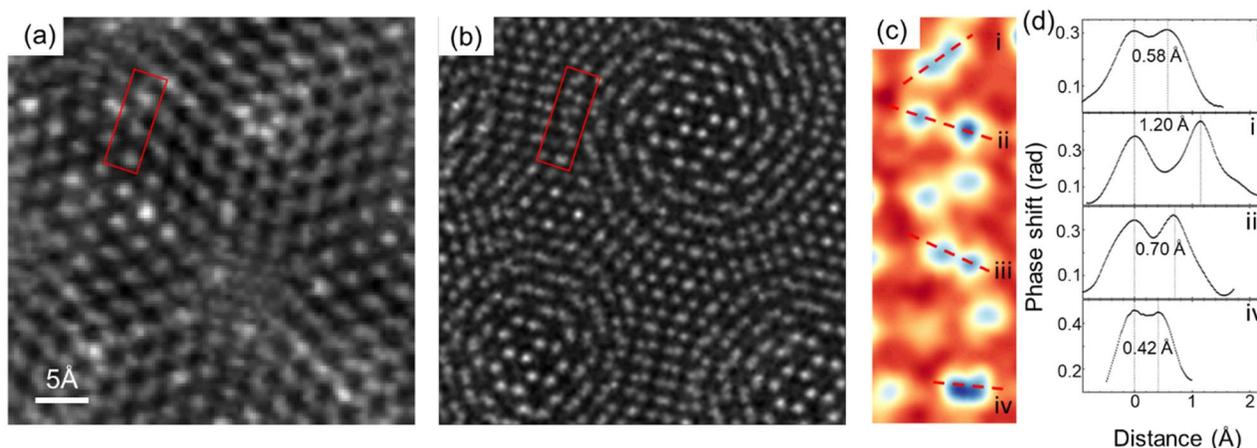
For a real-space resolution test, we imaged a twisted bilayer of MoS<sub>2</sub> with twist angle ~6.8°. This forms a Moiré pattern with a systematic range of separations between the projected atoms. The ptychographic reconstruction in Figure 2(b) shows many resolved atomic pairs that could not be resolved in the ADF image in Figure 2(a). Figure 2(c) shows an enlarged view of closely spaced atoms and the line profiles in Figure 2(d) show four selected peak-peak separations that approach resolution limit. The peak separation with  $0.42 \pm 0.02$  Å still contains a 6% dip at the middle point while more closely spaced atoms lose the central dip at just below 0.4 Å, which defines the Sparrow resolution limit, close to the Abbe resolution estimated in Figure 1(h) [6].

## References:

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**Figure 1.** Resolution improvement of ptychographic reconstructions of monolayer MoS<sub>2</sub> with increasing collection angle. (a) Synthesized ADF image from the same EMPAD dataset. Ptychographic reconstructions applying different cutoffs: (b) only the central bright field disk (1 $\alpha$ ), (c) up to 2 $\alpha$ , and (d) up to 4 $\alpha$ . (e)-(h) Diffraction patterns corresponding to (a)-(d) with white circles showing the information limit. 5 $\alpha$  corresponds to a 0.39 Å Abbe resolution. The red arrows point out a sulfur mono-vacancy.



**Figure 2.** Real-space resolution demonstration of full-field ptychography using a twisted bilayer MoS<sub>2</sub>. (a) Synthesized ADF image; (b) Phase image from ptychographic reconstruction of the same region as (a); (c) Enlarged phase image of the marked area in (b); (d) Intensity line profile of corresponding positions labeled with dashed red lines in (c). The peak separation distances are labelled in (d).